




Electronic Filing System (EFS) Data
Electronic Patent Application Submission
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EFS ID: 50150
Application ID: 10613620 
Title of Invention: Simple Chemical Vapor
Deposition System and Methods
for Depositing Multiple-Metal
Aluminide Coatings
First Named Inventor: David Fairbourn
Domestic/Foreign Application: Domestic Application
Filing Date: 2003-11-04
Effective Receipt Date: 2003-11-04
Submission Type: Information Disclosure
Statement
Filing Type:
Confirmation number: 4378
Attorney Docket Number: MTCL09

Total Fees Authorized:


Digital Certificate Holder: cn=William R. Allen,ou=Registered Attorneys,ou=Patent and Trademark
Office,ou=Department of Commerce,o=U.S. Government,c=US
Certificate Message Digest: e6e818039fbce1fb9bf8adb344b8223deef6eb92



TRANSMITTAL

Electronic Version v1.1

Stylesheet Version v1.1.0

Title of Invention	Simple Chemical Vapor Deposition System and Methods for Depositing Multiple-Metal Aluminide Coatings									
Application Number: 10/613620 										
Date: 2003-11-04										
First Named Applicant: David C Fairbourn										
Confirmation Number: 4378										
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<table border="1"><thead><tr><th>Submitted by:</th><th>Elec. Sign.</th><th>Sign. Capacity</th></tr></thead><tbody><tr><td>William R Allen Registered Number: 48389</td><td>William R. Allen</td><td>Attorney</td></tr></tbody></table>			Submitted by:	Elec. Sign.	Sign. Capacity	William R Allen Registered Number: 48389	William R. Allen	Attorney		
Submitted by:	Elec. Sign.	Sign. Capacity								
William R Allen Registered Number: 48389	William R. Allen	Attorney								
<table><tr><td>Documents being submitted</td><td>Files</td></tr><tr><td>us-ids</td><td>MTCL09-usidst.xml</td></tr><tr><td></td><td>us-ids.dtd</td></tr><tr><td></td><td>us-ids.xsl</td></tr></table>			Documents being submitted	Files	us-ids	MTCL09-usidst.xml		us-ids.dtd		us-ids.xsl
Documents being submitted	Files									
us-ids	MTCL09-usidst.xml									
	us-ids.dtd									
	us-ids.xsl									
Comments										



ELECTRONIC INFORMATION DISCLOSURE STATEMENT

Electronic Version v18
Stylesheet Version v18.0

Title of Invention

Simple Chemical Vapor Deposition System and Methods for
Depositing Multiple-Metal Aluminide Coatings

Application Number: 10/613620



Confirmation Number: 4378

First Named Applicant: David Fairbourn

Attorney Docket Number: MTCL09

Search string: (2598957 or 2816048 or 3329601 or 3486927
or 3507248 or 3556744 or 3801357 or 3979534
or 4084025 or 4101714 or 4220460 or 4327134
or 4396213 or 4427720 or 4641603 or 4625678
or 4694036 or 4699084 or 4687684 or 4816291
or 4961958 or 4935193 or 4963395 or 5071678
or 5114559 or 5261963 or 5308399 or 5368648
or 5377429 or 5439525 or 5451258 or 5455071
or 5632820 or 5750436 or 5820641 or 5823416
or 5851293 or 5902406 or 6083321 or 6089184
or 6143361 or 6156123 or 6254983 or 6258461
or 6332926 or 6605161).pn.

US Patent Documents

Note: Applicant is not required to submit a paper copy of cited US Patent Documents

init	Cite.No.	Patent No.	Date	Patentee	Kind	Class	Subclass
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	2	2816048	1957-12-10	Galmiche		117	107
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	46	6605161	2003-08-12	Fairbourn	B2	148	243

Signature

Examiner Name	Date